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Supporting Information

Room Temperature Ultrafast Synthesis of N- and O- Rich Graphene Films with Expanded interlayer distance for High Volumetric Capacitance Supercapacitor

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The calculation of the electrochemical measurement results

The gravimetric capacitance was calculated by CV curves as follows:

$$C_g = \frac{\int I dU}{2\nu m \Delta V} \tag{1}$$

Where C_g (F g⁻¹), v (V s⁻¹), m (g), ΔV (V) and I (A) represents the gravimetric capacitance, the scan rate, the mass of electrode material, the potential window of CV curves, the response-current of CV curves, respectively.

The gravimetric capacitance was calculated by GCD curves using the following equations:

$$C_g = \frac{It}{m\Delta V}$$
(2)
(For three electrode system)

$$C_g = \frac{2It}{m\Delta V} \tag{3}$$

(For two electrode system)

Where C_g (F g⁻¹) is the gravimetric capacitance, m (g) is the mass of a single electrode material, ΔV (V) is the potential window of GCD curves (exclude IR drop), I (A) is the discharge current and t is the discharge time (s).

The volumetric capacitance was calculated using the following equation:

$$C_v = C_g \times \rho \tag{4}$$

Where C_v (F cm⁻³) is the volumetric capacitance, C_g (F g⁻¹) is the gravimetric capacitance and ρ (g cm⁻³) is the density of electrode.

The volumetric energy density and power density was calculated using the following equation:

$$E_v = \frac{1}{3.6 \times 8} C_V \Delta V^2$$

$$P_v = \frac{3600E_v}{t}$$
(5)
(6)

Where E_v (Wh L⁻¹) is the volumetric energy density, C_v (F cm⁻³) is the volumetric capacitance, ΔV (V) is the potential window (exclude IR drop), P_v (W L⁻¹) is the the volumetric power density and t (s) is the discharge time.



Fig. S1 The digital photo of (a) GO film and (b) RGO film.



Fig. S2 UV-vis absorption spectra of MB solution after 48 h absorption by RGO and F-RGO-X (X=20, 40, 60).



Fig. S3 XPS survey spectra of F-RGO-20 and F-RGO-40.

| Sample | C=C/C-C | C-0 | С=О | 0-C=0 |
|----------|---------|--------|-------|-------|
| RGO | 81.47% | 13.23% | 5.3% | 0% |
| F-RGO-60 | 69.27% | 21.67% | 7.04% | 2.02% |

 Table S1. Atomic percentage of different functional groups.



Fig. S4 Water contact angle of (a) RGO, (b) F-RGO-20, (c) F-RGO-40, (d) F-RGO-60.



Fig. S5 CV curves of (a) RGO, (b) F-RGO-20, (c) F-RGO-40, (d) F-RGO-60 at different scan rate.



Fig. S6. GCD curves of (a) RGO, (b) F-RGO-20, (c) F-RGO-40, (d) F-RGO-60 at different current density.



Fig. S7 (a) CV curves of F-RGO-80 at different scan rates. (b) GCD curves of F-RGO-80 at different current densities. (c) Comparison of specific capacitances versus current densities. (d) Nyquist plots of F-RGO-80.

| Materials | Density (g cm ⁻³) | Electrolyte | Test | C _g (F g ⁻¹) | C _v (F cm ⁻³) |
|--|----------------------------------|--------------------------------------|-----------------------|--|---|
| Ternary-doped holey graphene hydrogel ¹ | 0.67 | 1.0 M H ₂ SO ₄ | 1 A g ⁻¹ | 350 | 234* |
| Graphene–carbon nanosphere films ² | 1.4 | 6.0 M KOH | 1 A g ⁻¹ | | 252 |
| Graphene–CNT films ³ | 1.5 | 6.0 M KOH | 1 A g ⁻¹ | | 250 |
| the reduced holey graphene films ⁴ | 1.14 | 1.0 M H ₂ SO ₄ | 1 A g ⁻¹ | 260 | 297* |
| Activated carbon- graphene ⁵ | 0.76 | 6.0 M KOH | 1 A g ⁻¹ | | 120 |
| Folded Graphene Ribbon Film ⁶ | 0.92 | 6.0 M KOH | 2 mV s ⁻¹ | 318 | 293* |
| Iodine-steam doped graphene films ⁷ | | 6.0 M KOH | 0.2 A g ⁻¹ | 150 | |
| Carbon fiber- graphene ⁸ | 0.00075 | 1.0 M H ₂ SO ₄ | 1 A g ⁻¹ | 215 | 0.161* |
| Defect-enriched graphene block ⁹ | 0.917 | 6.0 M KOH | 1 A g ⁻¹ | 235 | 215* |
| 3D porous RGO film ¹⁰ | 0.95 | 1.0 M H ₂ SO ₄ | 1 A g ⁻¹ | 181.3 | 172.3 |
| TL:1 | 1.47 | 6.0 M KOH | 1 A g ⁻¹ | 217.3 | 319.4* |
| 1 nis work | | | 0.1 A g ⁻¹ | 178.6 | 262.5 |

Table S2. Comparison of electrochemical performances of graphene based materials in aqueous electrolyte.

*represent the three-electrode system



Fig. S8 (a) CV curves of F-RGO-60 in 0.5 M Na_2SO_4 with a three-electrode configuration. (b) Comparison of specific capacitances versus scan rates.



Fig. S9 Electrical conductivity of RGO film and F-RGO-X (X=20, 40, 60 and 80).



Fig. S10 Capacitive contribution of (a) RGO, (b) F-RGO-20, (c) F-RGO-40, (d) F-RGO-60 at the scan rate of 20 mV s⁻¹.

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